Quantum anomalous Hall effect by coupling heavy atomic layers with CrI₃

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We explored the possibility of realizing quantum anomalous Hall effect by placing a heavy-element atomic layer on top of monolayer CrI₃ with a natural cleavage surface and broken time-reversal symmetry. We showed that CrI_3/X (X = Bi, Sb, or As) systems can open up a sizable bulk gap to harbor a quantum anomalous Hall effect; e.g., CrI_3/Bi is a natural magnetic insulator with a bulk gap of 30 meV, which can be further enlarged via strain engineering or adjusting spin orientations. We also found that the ferromagnetic properties (magnetic anisotropic energy and Curie temperature) of pristine CrI_3 can be further improved due to the presence of heavy atomic layers, and the spin orientation can be utilized as a useful knob to tune the band structure and Fermi level of the CrI_3/Bi system. The topological nature, together with the enhanced ferromagnetism, can unlock potential applications for CrI_3 -based materials in spintronics and electronics.

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I. INTRODUCTION

The interplay of symmetry, spin-orbit coupling, and magnetic structure together helps realize various topological phases ranging from quantum Hall effect to topological superconductor. The quantum anomalous Hall effect or magnetic topological insulator corresponds to the quantum Hall effect without applying external magnetic field [1-3], and exhibits immense application potential in dissipationless quantum electronics [4–8]. Typically, an element possessing high spin-orbit coupling is usually magnetically inactive, and vice versa. Therefore, the magnetic topological insulator rarely exists in natural materials. Theoretically, many attempts have been implemented to make it realistic in a single system by doping/adsorption [8-18], chemical functionalization [19,20], and heterostructure schemes [21-25]. However, thus far, experimentally, the quantum anomalous Hall effect has been only observed in magnetic element-doped topological insulators at very low temperatures [26-28]. It is noteworthy that a temperature record of 3.5 K for observing the quantum anomalous Hall effect was reported in the MnBi₂Te₄ system [29].

It has been proposed [30] that magnetic topological insulators may be realized by depositing heavy-element layers on top of the surface of non–van der Waals (non-vdW) magnetic insulators. However, such a strategy has several experimental complications, such as surface reconstruction due to the existence of dangling bonds on the surface of substrates. Owing to the presence of strong chemical bonding between constituent layers, it is experimentally not easy to downsize the vertical dimension of non-vdW three-dimensional (3D) ferromagnetic/antiferromagnetic insulators while preserving the lateral surface geometry (or only changing it slightly). To push away all these practical barriers and make the ideal environment more realistic, here we suggest a versatile experimental welcoming platform based on 2D vdW ferromagnetic insulators as a substrate for the deposition of heavy spinorbit coupling components. Unlike a non-vdW substrate, 2D vdW ferromagnetic insulators, in principle, possess a natural cleavage plane with a perfect surface geometry free from dangling bonds, have no surface reform complication, are free of spin alignments, and are more accessible to being synthesized experimentally with excellent stability. This may attract the experimental community to invest their efforts in probing magnetic topological insulators. In addition, we address the following key queries to advance possibly superior routes for magnetic topological insulators. (i) Can the addition of spin-orbit coupling drive trivial 2D vdW ferromagnetic systems to become large-band-gap magnetic topological insulators in a fundamental and controlled way? (ii) Can they improve the ferromagnetic properties of 2D vdW ferromagnetic insulators, such as the Curie temperature in these systems?

In this paper, we theoretically report that several candidate systems CrI_3/X (X = Bi, Sb, or As) present nontrivial magnetic topological behaviors with a sizable band gap, by employing the state-of-art first-principles calculation methods. Besides a robust magnetic topology with nonzero Chern numbers, notable enhancements of the ferromagnetic properties of pristine CrI_3 include the local magnetic anisotropic energy and Curie temperature after coupling with heavy-atomic layers. Furthermore, we showed that either the ferromagnetic orientation or the strain effect can be utilized to tune the topologically nontrivial band gaps.

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FIG. 1. (a) Crystal structure of Bi monolayer on monolayer CrI_3 (labeled as CrI_3/Bi), and Bi atoms (blue spheres) form a triangular lattice over the substrate; (b) first Brillouin zone of CrI_3/Bi along high symmetry lines; (c) side view of CrI_3/Bi .

II. FERROMAGNETIC PROPERTIES OF CrI₃/X

We launched our search for stable configurations comprised of a heavy-atoms monolayer, such as Bi, Sb, and As on the single-layer ferromagnetic insulator CrI₃, to realize the quantum anomalous Hall effect in these systems. Upon a careful examination, we found that deposited heavy elements on CrI₃ finally formed a monolayer with a triangular lattice structure, as displayed in Fig. 1(a). The evaluated interlayer binding energies for CrI₃/Bi, CrI₃/Sb, and CrI₃/As were -0.65, -0.62, and -0.58 eV per unit cell, respectively. To our surprise, we found a significant improvement in the magnetic moment of Cr in CrI_3/X systems, as listed in Table I. This is understandable, because the apparent interface interaction can change the charge distribution in CrI₃ when heavy atomic layers are deposited on CrI₃. As a result, the magnetic moments can be modified. This is indeed the case. Table I displays that the charges of Cr in CrI₃ and CrI₃/Bi are 2.17e and 1.94e, respectively, which indicate an additional 0.23e transferring from Bi to Cr after the deposition of the Bi monolayer. The same situation occurs for CrI₃/Sb and CrI_3 /As systems. However, the magnitude of charge transfer decreases from Bi to As atomic layers. This is reasonable because the attraction ability of the nucleus on the valence electrons becomes weaker, and then, the probability of charge transfer is increased when we move from As to Bi in the periodic table. Thus, the magnetic moment of Cr atoms in a

TABLE I. Bader charge analysis for CrI_3/X systems. $\triangle Q$ represents the charge difference on Cr and iodine after the deposition of heavy atomic layers on CrI_3 monolayer. Magnetic moments of each Cr atom, Heisenberg exchange constants, and Curie temperatures are symbolized by M, J, and T_C for CrI_3/X systems, respectively.

System	riangle Q		Magnetic properties		
	Cr	Ι	$\overline{M_{\rm Cr}(\mu_B)}$	J (meV)	<i>T</i> _C (K)
CrI ₃	0	0	3.0	2.59	44
CrI ₃ /Bi	0.23	0.27	3.72	9.62	165
CrI ₃ /Sb	0.21	0.24	3.70	7.10	122
CrI ₃ /As	0.11	0.14	3.62	6.37	110

CrI₃ single layer can be obviously enlarged by coupling with heavy atomic layers.

By depositing heavy atomic layers, the local magnetic moments of Cr in CrI3 are considerably increased. However, what about the magnetic coupling between these enhanced magnetic moments? We found that the resulting ferromagnetic coupling in CrI₃ can also be enhanced. From our calculations, the ferromagnetic stabilities were $\triangle E_{\text{FM}-\text{AFM}} = -130, -96,$ and -86 meV for CrI₃/Bi, CrI₃/Sb, and CrI₃/As systems, respectively, where $\triangle E_{\text{FM}-\text{AFM}}$ represents the energy difference between ferromagnetic and antiferromagnetic arrangements. This indicates that the ferromagnetic nature of monolayer CrI₃ can be further stabilized by interacting with X(=Bi, Sb, As)atomic layers. In principle, the improvement of ferromagnetic stability boosts the Heisenberg exchange constant J. Our estimated Heisenberg exchange constants are respectively 9.62, 7.10, and 6.37 meV for CrI_3/Bi , CrI_3/Sb , and CrI_3/As . These are much higher than that of monolayer CrI_3 (~2.59 meV) [31]. Based on the above data and the mean-field theory, the estimated Curie temperatures are 165, 122, and 110 K for CrI₃/Bi, CrI₃/Sb, and CrI₃/As, respectively [32]. These are greatly enhanced from ~44 K of monolayer CrI₃. In particular, a high Curie temperature is tall-demandable for quantum anomalous Hall system to operate at moderate temperatures in future device applications.

After determining that CrI_3/X systems favor the ferromagnetic ground state, we then proceeded to investigate the magnetic anisotropy. Our results showed that the *z* axis is an easy magnetization direction for the CrI_3/Bi system, which is approximately 5 meV (per unit cell with two Cr atoms) lower than that of the *x* axis. This value is much higher than that of monolayer CrI_3 (~1.5 meV). This obvious improvement in magnetic anisotropic energy arises from the strong spinorbit coupling in CrI_3/Bi , which has been reported in various systems [33,34].

III. QUANTUM ANOMALOUS HALL EFFECT

The enhancement in ferromagnetic properties of pristine CrI₃, including the local magnetic moments, Heisenberg exchange interactions, magnetic anisotropic energy, and Curie temperature, will be beneficial to realizing the quantum anomalous Hall effect in CrI₃ after coupling with heavyatomic layers. Figure 2(a) displays the spin-polarized band structure of CrI₃/Bi. The spin-up and -down bands cross around Γ to form D_{1/2} points, which are closely located near the Fermi level. Considering the presence of Bi states at the Fermi level [32], together with the conceptual framework of magnetic topological insulators, one may expect the formation of a topological nontrivial insulator around these avoided band-crossing points. When spin-orbit coupling is further considered in CrI₃/Bi, the degenerate states at the avoided band-crossing points repel each other to open up an energy gap [see Fig. 2(b)]. Our achieved direct and indirect (global) band gaps in the CrI₃/Bi are respectively 30 and 75 meV. We also confirmed the nontrivial behavior inside the band gap by calculating the Chern number using the approach implemented in Wannier90 and WannierTools packages [35,36]. Our calculations demonstrate that CrI₃/Bi indeed harbors a



FIG. 2. (a),(c),(e) Spin-polarized band structures of CrI₃/Bi (a), CrI₃/As (c), and CrI₃/Sb (e), respectively. (b),(d),(f) Band structures with spin-orbit coupling of CrI₃/Bi (b), CrI₃/As (d), and CrI₃/Sb (f), respectively. Blue and red colors denote spin-up and -down bands. Here, C, C_{cb} , and C_{vb} represent the Chern numbers when the Fermi level locates in the band gap at zero, positive (conduction bands), and negative (valence bands) energies respectively.

quantum anomalous Hall effect associated with a nonzero Chern number of C = -1 [37].

Figure 2(c) displays the spin-polarized band structure for CrI₃/As. We found that the spin-up band crosses the spindown bands twice within the energy window from 3.4 to 3.7 eV around Γ point. These band-crossing points are labeled as $\delta_{1/2}$. Interestingly, the band structures around these crossing points resemble the ideal cone (Dirac point) in graphene. Due to the relatively strong spin-orbit coupling of As, one may expect a nontrivial band gap to open around these Dirac points when spin-orbit coupling is invoked. Figure 2(d) presents the band structure in the presence of spin-orbit coupling, where band gaps open up around the crossing points of $\delta_{1/2}$, which clearly indicate the existence of nontrivial band topologies in the conduction bands of CrI₃/As. By using the abovementioned approach, we obtained the Chern number of $C_{cb} =$ 2 for the corresponding opened band gaps. Additionally, the two valence bands touch each other around the K point [32]. When the spin-orbit coupling is switched on, band gaps are opened at these touching points, which signifies the topological nature of the CrI₃/As in valence bands. In principle, the nontrivial local band gap in the conduction bands of CrI₃/As can be converted into an insulator by the charge doping technique, which is equivalent to the electrostatic gating in experiment. To tune the Fermi level into the conduction band, we applied a homogeneous background charge to electrostatically control the electron doping using the self-consistent simulation approach. We noticed that the Fermi level was correctly located into the spin-orbit coupling induced band gap without affecting the band-structure pattern when the homogeneous charge of $\triangle Q = 1e$ was functionalized [32]. Notably, the nontrivial band gap is also widened from 18 to 37 meV upon the functionalization of electrostatic doping [32]. Thus, CrI₃/As can also become a quantum anomalous Hall insulator upon moderate electrostatic gating.

Figure 2(e) displays the spin-polarized band structure of CrI₃/Sb. The spin-up and -down bands cross each other multiple times in the energy range between -1.30 and -1.15 eV. A nontrivial band gap opens at these crossing points upon the application of spin-orbit coupling [see Fig. 2(f)]. The global band gap is approximately 65 meV, and exhibits a nontrivial topological nature with a Chern number of $C_{vb} = 1$. Similar electrostatic gating approach can be used to tune the Fermi level into the band gap.

IV. SPIN ORIENTATION EFFECT

The orientation of spin moments along different crystallographic directions provides one way to control the band structure and its associated topologically nontrivial properties. Very recently, several scientific phenomena have been reported so far, whereby changing the magnetization direction significantly modifies the electronic band structure. For instance, by adjusting the spin moments in the horizontal plane of CrI₃ with the application of magnetic field, an electronic phase transition occurs from indirect to direct band-gap semiconductor, which could be useful to develop magnetooptoelectronic devices where the photoconductivity can be switched by an external magnetic field [38]. Similarly, spin orientation could also serve as a new degree of freedom for the manipulation of the topological states in two-dimensional magnetic monolayers [4,39,40]. Since a variety of characteristics alter with band structure, therefore, materials with electronic properties linked with the variation of spin direction can be practiced to realize new types of spintronics devices, which could be simple in structure and smaller in size as compared to the traditional spintronics devices. In a broader context, a strong spin-orbit coupling, together with a less symmetric crystallographic structure and a suitable magnetic behavior, is the main parameter to explore the spin orientation effect. Fortunately, 2D CrI_3/X systems fulfill all these criteria, and hence are promising candidate platforms for demonstrating the spin orientation effects. In Fig. 3, our calculations show that tuning the spin moment from the c to a axis in the CrI_3/Bi system remarkably modifies the band structures, including substantially changing the Fermi surface and band gaps. In particular, one can observe that when all spin moments were adjusted in a ferromagnetic pattern from 0° to 68° , the band gap first gradually increases and then quickly decreases to be closed. Beyond $\theta = 68^{\circ}$, the CrI₃/Bi system undergos a topological phase transition from the quantum anomalous Hall effect to a magnetic metallic state.

V. STRAIN EFFECT

Strain is one of the significant approaches for engineering electronic and topological properties. Fortunately, the softness level of monolayer CrI_3 is higher than that of graphene and MoS_2 , indicating that monolayer CrI_3 can be easily stretched or compressed experimentally [41]. From this perspective, we examined the CrI_3/Bi system under the application of



FIG. 3. Effect of spin orientation on the band structure of the CrI₃/Bi system with SOC effects included. (a)-(f) present the SOC-included band structure when all spins are aligned at angles of 0° , 15° , 30° , 45° , 68° , and 90° , respectively. (g) The variation in the direct and indirect bandgaps in CrI₃/Bi as a function of θ , where angle θ is measured in degrees from the vertical axis. The blue and red curves correspond to the indirect and direct bandgaps, respectively.

several biaxial strains ranging from -5 to 5% (see Fig. 4). We observed that both direct and indirect band gaps are very sensitive to the strain. In the upper panels, we considered the out-of-plane magnetization along the vertical direction with $\theta = 0^{\circ}$. It is observed that the global band gap considerably increases when the lattice is allowed to compress within the horizontal plane. Interestingly, the nature of the global band gap changes from indirect to direct at an approximately 3.15% compressive strain (see Fig. 4), while for the in-plane magnetization with $\theta = 90^{\circ}$ (see lower panels), one can find that the global band gap remains closed in the typical range of tensile strains. Similarly, the global band gap remains zero against the compressive strain. However, surprisingly, the zero nature of the global band gap converts into a nonzero one when the compressive strain is increased beyond 4%, as shown in Fig. 4(h). This band gap progressively enlarges upon a further increase in compressive strain. Therefore, in CrI₃/Bi, the quantum anomalous Hall effect with a Chern number of C = 1 can also be realized even in the presence of in-plane magnetization at a compressive strain slightly larger than 4%.



FIG. 4. (a)–(d) Band structures with out-of-plane magnetization in the presence of compressive strains, i.e., -1% (a), -3.15% (b), and -4% (c); (d) band gaps (direct and indirect) as function of compressive strain. (e)–(h) Band structures with in-plane magnetization in the presence of compressive strains, i.e., -4% (e), -5%(f), and -6% (g); (h) band gaps (direct and indirect) as function of compressive strain. ε symbolizes the strain in %.

VI. SUBSTRATE PROTOTYPE

Finally, we considered CrI_3 /Bi as a representative example to search for an experimentally suitable nonmagnetic substrate that guarantees the survival of Dirac points around the Fermi level. We found that $MoTe_2$ (001) can serve as a good nonmagnetic substrate [32]. Our projected principles for discovering quantum anomalous Hall materials can be straightforwardly extended to other vdW 2D ferromagnetic systems. Because of the epitaxial techniques, it becomes much more convenient to artificially enlarge the family of 2D vdW ferromagnetic materials. Compared to traditional spintronic devices that are comprised of magnetic materials with some finite thickness, vdW ferromagnetic materials can simplify the device structure and shrink the device dimensions.

VII. SUMMARY

Based on density functional theory, we confirmed that CrI₃/Bi system is a quantum anomalous Hall insulator with a direct band gap of approximately 30 meV at the Fermi level. We observed that CrI₃/As and CrI₃/Sb can open up topologically nontrivial band gaps in their conduction and valence bands, which can be properly tuned close the Fermi level via moderate electrostatic gating. Apart from the stable topology, we also found a major development in the ferromagnetic properties of CrI₃, including local magnetic moments, Heisenberg exchange interactions, magnetic anisotropic energy, and Curie temperatures by coupling with atomic layers of Bi/As/Sb. Furthermore, we showed that the band gaps of our proposed systems can be efficiently manipulated via tuning spin orientation or applying strain. Our study of the CrI_3/X system can open routes to explore the quantum anomalous Hall effect based on 2D ferromagnetic insulators together with the potential application of CrI₃-based materials in spintronics.

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